

# Dry Etching Equipment Market Report: Trends, Forecast and Competitive Analysis to 2030

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## Abstracts

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### Dry Etching Equipment Trends and Forecast

The future of the global dry etching equipment market looks promising with opportunities in the logic and memory, MEMS, and power device applications. The global dry etching equipment market is expected to reach an estimated \$14.8 billion by 2030 with a CAGR of 6.2% from 2024 to 2030. The major drivers for this market are increasing demand for miniaturized electronic devices, growing adoption of semiconductor components in various industries, and rapid advancements in nanotechnology and semiconductor manufacturing processes.

A more than 150-page report is developed to help in your business decisions. Sample figures with some insights are shown below.

### Dry Etching Equipment by Segment

The study includes a forecast for the global dry etching equipment by type, application, and region.

Dry Etching Equipment Market by Type [Shipment Analysis by Value from 2018 to 2030]:

Inductively Coupled Plasma (ICP)

Capacitive Coupled Plasma (CCP)

Reactive Ion Etching (RIE)

Deep Reactive Ion Etching (DRIE)

Others

Dry Etching Equipment Market by Application [Shipment Analysis by Value from 2018 to 2030]:

Logic and Memory

MEMS

Power Device

Others

Dry Etching Equipment Market by Region [Shipment Analysis by Value from 2018 to 2030]:

North America

Europe

Asia Pacific

The Rest of the World

List of Dry Etching Equipment Companies

Companies in the market compete on the basis of product quality offered. Major players in this market focus on expanding their manufacturing facilities, R&D investments, infrastructural development, and leverage integration opportunities across the value chain. With these strategies dry etching equipment companies cater increasing demand, ensure competitive effectiveness, develop innovative products & technologies,

reduce production costs, and expand their customer base. Some of the dry etching equipment companies profiled in this report include-

Lam Research

TEL

Applied Materials

Hitachi High-Technologies

Oxford Instruments

ULVAC

SPTS Technologies

GigaLane

Plasma-Therm

SAMCO

## Dry Etching Equipment Market Insights

Lucintel forecasts that deep reactive ion etching is expected to witness the highest growth over the forecast period.

Within this market, MEMS is expected to witness the highest growth over the forecast period.

APAC will remain the largest region over the forecast period.

## Features of the Global Dry Etching Equipment Market

Market Size Estimates: Dry etching equipment market size estimation in terms of value (\$B).

**Trend and Forecast Analysis:** Market trends (2018 to 2023) and forecast (2024 to 2030) by various segments and regions.

**Segmentation Analysis:** Dry etching equipment market size by type, application, and region in terms of value (\$B).

**Regional Analysis:** Dry etching equipment market breakdown by North America, Europe, Asia Pacific, and Rest of the World.

**Growth Opportunities:** Analysis of growth opportunities in different types, applications, and regions for the dry etching equipment market.

**Strategic Analysis:** This includes M&A, new product development, and competitive landscape of the dry etching equipment market.

Analysis of competitive intensity of the industry based on Porter's Five Forces model.

## FAQ

**Q1. What is the dry etching equipment market size?**

**Answer:** The global dry etching equipment market is expected to reach an estimated \$14.8 billion by 2030.

**Q2. What is the growth forecast for dry etching equipment market?**

**Answer:** The global dry etching equipment market is expected to grow with a CAGR of 6.2% from 2024 to 2030.

**Q3. What are the major drivers influencing the growth of the dry etching equipment market?**

**Answer:** The major drivers for this market are increasing demand for miniaturized electronic devices, growing adoption of semiconductor components in various industries, and rapid advancements in nanotechnology and semiconductor manufacturing processes.

**Q4. What are the major segments for dry etching equipment market?**

Answer: The future of the dry etching equipment market looks promising with opportunities in the logic and memory, MEMS, and power device applications.

Q5. Who are the key dry etching equipment market companies?

Answer: Some of the key dry etching equipment companies are as follows:

Lam Research

TEL

Applied Materials

Hitachi High-Technologies

Oxford Instruments

ULVAC

SPTS Technologies

GigaLane

Plasma-Therm

SAMCO

Q6. Which dry etching equipment market segment will be the largest in future?

Answer: Lucintel forecasts that deep reactive ion etching is expected to witness the highest growth over the forecast period.

Q7. In dry etching equipment market, which region is expected to be the largest in next 5 years?

Answer: APAC will remain the largest region over the forecast period.

Q.8 Do we receive customization in this report?

Answer: Yes, Lucintel provides 10% customization without any additional cost.

This report answers following 11 key questions:

Q.1. What are some of the most promising, high-growth opportunities for the dry etching equipment market by type (inductively coupled plasma (ICP), capacitive coupled plasma (CCP), reactive ion etching (RIE), deep reactive ion etching (DRIE), and others), application (logic and memory, MEMS, power device, and others), and region (North America, Europe, Asia Pacific, and the Rest of the World)?

Q.2. Which segments will grow at a faster pace and why?

Q.3. Which region will grow at a faster pace and why?

Q.4. What are the key factors affecting market dynamics? What are the key challenges and business risks in this market?

Q.5. What are the business risks and competitive threats in this market?

Q.6. What are the emerging trends in this market and the reasons behind them?

Q.7. What are some of the changing demands of customers in the market?

Q.8. What are the new developments in the market? Which companies are leading these developments?

Q.9. Who are the major players in this market? What strategic initiatives are key players pursuing for business growth?

Q.10. What are some of the competing products in this market and how big of a threat do they pose for loss of market share by material or product substitution?

Q.11. What M&A activity has occurred in the last 5 years and what has its impact been on the industry?

For any questions related to Dry Etching Equipment Market, Dry Etching Equipment Market Size, Dry Etching Equipment Market Growth, Dry Etching Equipment Market Analysis, Dry Etching Equipment Market Report, Dry Etching Equipment Market Share,

Dry Etching Equipment Market Trends, Dry Etching Equipment Market Forecast, Dry Etching Equipment Companies, write Lucintel analyst at email: [helpdesk@lucintel.com](mailto:helpdesk@lucintel.com). We will be glad to get back to you soon.

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